


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10/02/992
12/19/01

DC 844

PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

AFPL NUM 10027692	FILING DATE 12/19/2001	CLASS 148	SUBCLASS 554	GAU 1742	EXAMINER  Kastler
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*APPLICANTS: Kardokus Janine; Wu Chi; Parfeniuk Christopher; Bushler Jane;

*CONTINUING DATA VERIFIED:


THIS APPLICATION IS A DIV OF 09/714,714 11/15/2000 -17C
WHICH IS A CON OF 09/615,474 07/13/2000 PAT 6,331,234
WHICH IS A CON OF 09/324,299 02/02/1999 PAT 6,113,761

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*FOREIGN APPLICATIONS VERIFIED:

None

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Foreign priority claimed 35 USC 119 conditions met Verified and Acknowledged Examiners's initials 	ATTORNEY DOCKET NO JM34006D1V
TITLE: Methods of forming copper-containing sputtering targets	

U.S. DEPT. OF COMMERCE/PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
Assistant Examiner			
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drawn	Figs. Drawn
		Print Fig.	
Primary Examiner		Application Examiner	
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
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